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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/691,555	10/24/2003	David C. Lovetro	7490	
7:	590 07/21/2004		EXAM	INER
DAVID J. SERBIN			CARRILLO, BIBI SHARIDAN	
LAW OFFICE	OF DAVID J. SERBIN			
1217 KING STREET			ART UNIT	PAPER NUMBER
ALEXANDRIA, VA 22314			1746	

DATE MAILED: 07/21/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)				
	10/691,555	LOVETRO ET AL.				
Office Action Summary	Examiner	Art Unit				
	Sharidan Carrillo	1746				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
Status						
1) Responsive to communication(s) filed on 24 O	<u>ctober 2003</u> .					
2a) This action is <b>FINAL</b> . 2b) ☑ This	☐ This action is <b>FINAL</b> . 2b) ☐ This action is non-final.					
3) Since this application is in condition for allowar	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
<ul> <li>4)  Claim(s) 1-16 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdrawn from consideration.</li> <li>5)  Claim(s) is/are allowed.</li> <li>6)  Claim(s) 1-16 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or election requirement.</li> </ul>						
Application Papers						
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examine	epted or b) objected to by the liderawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of	s have been received. s have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
<ul> <li>2) Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)</li> <li>Paper No(s)/Mail Date 10/24/2003.</li> </ul>	Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te atent Application (PTO-152)				

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**DETAILED ACTION** 

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Claim Rejections - 35 USC § 112

1. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

2. Claims 1-16 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which

applicant regards as the invention.

Claims 1, 13 and 15 are indefinite because they fail to positively recite a step of cleaning the metal. The claims only recite a step of contacting the metal, which would not necessarily result in cleaning of the metal. Claims 2-3 are indefinite because it recites that the aqueous solution further comprises phosphonic acid, the limitations of which were previously recited in claim 1. Claim 13 is indefinite because it fails to positively recite hydrogen peroxide. Claims 14 and 16 are indefinite because it fails to recited diphosphonic acid. Claim 15 is indefinite because the surfactant is recited twice.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

4. Claims 1-2, 4,8 and 12 are rejected under 35 U.S.C. 102(b) as being anticipated by Brasch (4378270).

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In reference to claims 1-2 and 12, Brash teaches a method of removing copper from a circuit board by contacting with an aqueous solution comprising hydrogen peroxide and 0.1-20% by weight phosphonic acid (col. 3, lines 25-30, col. 4, lines 17-20, col. 2, lines 35-40). In reference to claims 4-5, refer to col. 3, lines 10-15. In reference to claim 6, refer to the Example, and col. 4, line 34. In reference to claims 7-8, refer to col. 4, line 22.

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 6. Claims 1 and 8-12 are rejected under 35 U.S.C. 102(e) as being anticipated by Skee (6599370).

Skee teaches stabilized alkaline compositions for cleaning microelectronic substrates, the composition comprising a) a base, b) a stabilizing agent, hydrogen peroxide, c) 0.01-10% chelant (phosphonic acid), and d) surfactant (Abstract, col. 8, lines 53-57, col. 6, line 45). In reference to claim 6, refer to col. 7, line 39, col. 10, line 66. In reference to claims 8-9, refer to col. 45, lines 60-63, col. 8, lines 50-52. In reference to claims 10-11, refer to col. 9, lines 15-19. In reference to claim 12, refer to col. 48, claim 26.

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## Claim Rejections - 35 USC § 103

7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 8. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - 3. Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 9. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 10. Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over Brasch (4378270).

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Brasch fails to teach 35-45% of phosphonic acids. However, it would have been within the level of the skilled artisan to adjust the concentration of phosphonic acid since Brasch teaches that higher concentrations can be used (col. 3, lines 25-30).

11. Claims 9, and 13-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Brasch (4378270) in view of Schellinger Jr. (4401509).

Brasch teaches the invention substantially as claimed with the exception of the concentration of sulfuric acid. Schellinger teaches a composition for etching copper from circuit boards using sulfuric acid, hydrogen peroxide, and phosphonic acid. In col. 3, lines 3-5, Schellinger teaches 2-20% sulfuric acid. Schellinger further teaches that the concentration of sulfuric acid is not critical.

It would have been obvious to a person of ordinary skill in the art to have modified the method of Brasch to include adjusting the concentration of sulfuric acid to 2-20%, as taught by Schellinger, for purposes of etching copper from integrated circuit boards.

Brasch, as modified by Schellinger, fail to teach 35-50% of phosphonic acids. However, it would have been within the level of the skilled artisan to adjust the concentration of phosphonic acid since Brasch teaches that higher concentrations can be used (col. 3, lines 25-30). In reference to claim 14, refer to the teachings of Brasch.

12. Claim 15 is rejected under 35 U.S.C. 103(a) as being unpatentable over Skee (6599370) in view of Morinaga et al. (5885362).

Skee teaches using an alkaline solution. Skee teaches that any suitable base

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may be used but fails to teach an alkali metal hydroxide. Morinaga et al. teach surface treatment (i.e. cleaning etching) using a composition comprising a base, surfactant, peroxide, and a chelant. In col. 12-13 bridging, Morinaga teaches forming an alkaline solution with bases which include ammonia, ammonium hydroxide, and alkali earth metal hydroxides. It would have been obvious to a skilled artisan to have modified the method of Skee to include equivalent bases, such as alkali metal hydroxides, as taught by Morinaga, for purposes of forming an alkaline solution.

13. Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Skee (6599370) in view of Morinaga et al. (5885362) and further in view of Watts (4070422).

Skee fails to teach the specific phosphonic acid as recited in claim 16. Watts teaches various phosphonic acids for stabilization of hydrogen peroxide. Col. 3, lines 25-29, teaches hydroxyethylidene 1,1-diphosphonic acid is preferred because of its commercial availability.

It would have been obvious to a person of ordinary skill in the art to have modified the method of Skee to include hydroxyethylidene 1,1-diphosphonic acid, as taught by Watts, for the advantages of commercial availability of the reagent.

14. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Sakamoto et al. teach an electroplating process. Sugihara et al. teach a cleaning fluid for a semiconductor substrate. Zhang et al. teach a composition comprising a surfactant, chelant, hydrogen peroxide, and base. Winkley teaches stabilized hydrogen peroxide solutions. Hayashida et al. teach cleaning the surface.

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15. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Sharidan Carrillo whose telephone number is 571-272-

1297. The examiner can normally be reached on Monday-Friday, 6:00a.m-2:30pm.

16. If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Michael Barr can be reached on 571-272-1414. The fax phone number for

the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

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bsc

SHARIDAN CARRILLO PRIMARY EXAMINER